

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Attorney Docket No.: UCF-287

Application Serial No.: 09/881,620

Filed: 06/14/01

Examiner: Thomas Courtney D.

Group: 2882

For: EUV, XUV, AND X-RAY WAVELENGTH SOURCES CREATED FROM LASER PLASMA PRODUCED FROM LIQUID METAL SOLUTIONS

INFORMATION DISCLOSURE STATEMENT

Honorable Commissioner of Patents
and Trademarks

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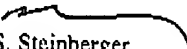
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TECHNOLOGY CENTER 2800

Pursuant to the requirements of 37 CFR 1.97 and 1.98, Applicant hereby requests that the references listed in the attached form PTO-1449 be considered and made of record in the above-identified application.

Favorable consideration of the application at an early date is respectfully solicited.

Respectfully submitted,


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SUPPLEMENTAL FORM PTO-1449

US DEPARTMENT OF COMMERCE
PATENT AND TRADEMARK OFFICE

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LIST OF ART CITED BY APPLICANT

U.S. PATENT DOCUMENTS

EXAMINER	DOCUMENT NO.	DATE	NAME	CLASS/SUBCLASS
AA	4,182,574	01/1980	Quillfeldt	356/119
AB	4,723,262	02/1988	Noda	378/119
AC	4,866,517	09/1989	Mochizuki	378/119
AD	4,953,191	08/1990	Smither	378/143
AE	5,052,034	09/1991	Schuster	378/121
AF	5,459,771	10/1995	Richardson	378/119
AG	5,577,092	11/1996	Kublak	378/119
AH	5,991,360	11/1999	Matsui	378/119
AI	6,285,743	09/2001	Kondo	378/119
AJ	6,304,630	10/2001	Bisschops	378/119
AK	6,493,423	12/2002	Bisschops	378/119

U. S. PUBLICATIONS

PA	US-2003/0108155A1	06/2001	Wilkins	378/119
PB	US-2002/0015473A1	02/2002	Hertz	378/143
PC	US-2002/0044629A1	04/2002	Hertz	378/119
PD	US-2002/0090054-A1	07/2002	Sogard	378/119

FOREIGN PATENT DOCUMENTS

FA WO 0130122 04/2001 Atomique

OTHER ART (INCLUDING AUTHOR, TITLE, DATE, PERTINENT PAGES, ETC.)

OA HERTZ, H. M., et al., Debris-Free Soft X-ray Generation Using a Liquid Droplet Laser-Plasma target, Department of Physics, Lund Institute of Technology, Sweden, SPIE Vol. 2523, pp. 88 -93

OB RYMELL, L., et al., Droplet Target for Low-Debris-Laser-Plasma Soft X-ray Generation, No. 1/2 pp. 105-110, Optics Communications, November (1993)